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## Amendments to the Claims:

This listing of claims replaces all prior versions and listings of claims in the application:

## Listing of Claims:

1. (Currently Amended) A semiconductor device having at least one thin film transistor, said thin film transistor comprising:

a semiconductor layer formed over a substrate, said semiconductor layer having source and drain regions and a channel formation region interposed therebetween; and

a gate electrode formed adjacent to said semiconductor layer,

wherein said semiconductor layer comprises crystals arranged in a direction substantially in which crystal grain boundaries are substantially aligned in a direction parallel with a length direction of said channel formation region,

wherein a standard deviation of S-value of said thin film transistor is within 10 mV/dec for an N-channel type and 15 mV/dec for a P-channel type.

- 2. (Original) A semiconductor device according to claim 1, wherein said semiconductor layer contains a metal element for promoting crystallization at a concentration of not higher than  $1 \times 10^{18}$  atoms/cm<sup>3</sup>.
- 3. (Original) A semiconductor device according to claim 1, wherein said semiconductor device is incorporated into an electronic apparatus selected from the group consisting of a TV camera, a head mounted display, a car navigation, a portable telephone, a video camera and a projector.
- 4. (Currently Amended) A semiconductor device having at least one thin film transistor, said thin film transistor comprising:

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a semiconductor layer formed over a substrate, said semiconductor layer having source and drain regions and a channel formation region interposed therebetween; and

a gate electrode formed adjacent to said semiconductor layer,

wherein said semiconductor layer comprises crystals arranged in a direction substantially in which crystal grain boundaries are aligned in a direction parallel with a length direction of said channel formation region,

wherein a length of said channel formation region is 0.01 to 2  $\mu$ m.

- 5. (Original) A semiconductor device according to claim 4, wherein said semiconductor layer contains a metal element for promoting crystallization at a concentration of not higher than  $1 \times 10^{18}$  atoms/cm<sup>3</sup>.
- 6. (Original) A semiconductor device according to claim 4, wherein said semiconductor device is incorporated into an electronic apparatus selected from the group consisting of a TV camera, a head mounted display, a car navigation, a portable telephone, a video camera and a projector.
- 7. (Currently Amended) A semiconductor device having at least one thin film transistor, said thin film transistor comprising:

a semiconductor layer formed over a substrate, said semiconductor layer having source and drain regions and a channel formation region interposed therebetween; and

a gate electrode formed adjacent to said semiconductor layer,

wherein said semiconductor layer comprises crystals arranged in a direction substantially in which crystal grain boundaries are aligned in a direction parallel with a carrier flow direction between said source and drain regions,

wherein a standard deviation of S-value of said thin film transistor is within 10 mV/dec for an N-channel type and 15 mV/dec for a P-channel type.

Applicant: Shunpei Yamazaki et al. Attorney's Docket No.: 07977-188002 / US

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8. (Original) A semiconductor device according to claim 7, wherein said semiconductor layer contains a metal element for promoting crystallization at a concentration of not higher than  $1 \times 10^{18}$  atoms/cm<sup>3</sup>.

- 9. (Original) A semiconductor device according to claim 7, wherein said semiconductor device is incorporated into an electronic apparatus selected from the group consisting of a TV camera, a head mounted display, a car navigation, a portable telephone, a video camera and a projector.
- 10. (Currently Amended) A semiconductor device having at least one thin film transistor, said thin film transistor comprising:

a semiconductor layer formed over a substrate, said semiconductor layer having source and drain regions and a channel formation region interposed therebetween; and

a gate electrode formed adjacent to said semiconductor layer,

wherein said semiconductor layer comprises crystals arranged in a direction substantially in which crystal grain boundaries are aligned in a direction parallel with a carrier flow direction between said source and drain regions,

wherein a length of said channel formation region is 0.01 to 2  $\mu$ m.

- 11. (Original) A semiconductor device according to claim 10, wherein said semiconductor layer contains a metal element for promoting crystallization at a concentration of not higher than  $1 \times 10^{18}$  atoms/cm<sup>3</sup>.
- 12. (Original) A semiconductor device according to claim 10, wherein said semiconductor device is incorporated into an electronic apparatus selected from the group consisting of a TV camera, a head mounted display, a car navigation, a portable telephone, a video camera and a projector.

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13. (Currently Amended) An active matrix display device comprising:

a pixel matrix circuit formed over a substrate;

a logic circuit formed over said substrate, said logic circuit having thin film transistors,

wherein each of said thin film transistors comprises:

a semiconductor layer formed over a substrate, said semiconductor layer having source and drain regions and a channel formation region interposed therebetween; and

a gate electrode formed adjacent to said semiconductor layer,

wherein said semiconductor layer comprises crystals arranged in a direction substantially in which crystal grain boundaries are aligned in a direction parallel with a length direction of said channel formation region,

wherein a standard deviation of S-value of said thin film transistor is within 10 mV/dec for an N-channel type and 15 mV/dec for a P-channel type.

- 14. (Original) An active matrix display device according to claim 13, wherein said semiconductor layer contains a metal element for promoting crystallization at a concentration of not higher than 1 x 10<sup>18</sup> atoms/cm<sup>3</sup>.
- 15. (Original) An active matrix display device according to claim 13, wherein said semiconductor device is incorporated into an electronic apparatus selected from the group consisting of a TV camera, a head mounted display, a car navigation, a portable telephone, a video camera and a projector.
  - 16. (Currently Amended) An active matrix display device comprising:

a pixel matrix circuit formed over a substrate;

a logic circuit formed over said substrate, said logic circuit having thin film

transistors,

wherein each of said thin film transistors comprises:

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a semiconductor layer formed over a substrate, said semiconductor layer having source and drain regions and a channel formation region interposed therebetween; and a gate electrode formed adjacent to said semiconductor layer,

wherein said semiconductor layer comprises crystals arranged in a direction substantially in which crystal grain boundaries are aligned in a direction parallel with a carrier flow direction between said source and drain regions,

wherein a standard deviation of S-value of said thin film transistor is within 10 mV/dec for an N-channel type and 15 mV/dec for a P-channel type.

- 17. (Original) An active matrix display device according to claim 16, wherein said semiconductor layer contains a metal element for promoting crystallization at a concentration of not higher than 1 x 10<sup>18</sup> atoms/cm<sup>3</sup>.
- 18. (Original) An active matrix display device according to claim 16, wherein said semiconductor device is incorporated into an electronic apparatus selected from the group consisting of a TV camera, a head mounted display, a car navigation, a portable telephone, a video camera and a projector.